

QUARTZ

Sputtering Target

NS6130-10-1553

Quick Facts

Product	:	Quartz Sputtering Target
Stock No	:	NS6130-10-1553
CAS	:	14808-60-7
Molecular Formula	:	SiO ₂
Form	:	Solid

Technical Specification

Diameter	Thickness	Purity
50.8mm	3mm	99.99%

Quartz sputtering targets are commonly used in the semiconductor industry for the deposition of dielectric films in the fabrication of integrated circuits and other electronic components. They are also used in the production of optical coatings for lenses and mirrors, as well as in the manufacture of solar cells and other photovoltaic devices.



* This image is for graphic purposes only and does not represent the actual product.

